

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of Applicants:

Date: December 28, 2005

Angelopoulos et al.

Group Art Unit: 1752

Serial No.: 09/256,034

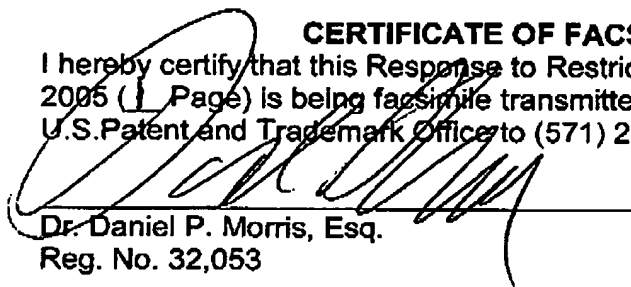
Examiner: J. Chu

Filed: February 23, 1999

Docket No: YO998-056

**RECEIVED
CENTRAL FAX CENTER****DEC 28 2005****For: MULTILAYERED RESIST SYSTEMS USING TUNED POLYMER
FILMS AS UNDERLAYERS AND METHODS OF FABRICATION THEREOF**Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450**CERTIFICATE OF FACSIMILE TRANSMISSION**

I hereby certify that this Response to Restriction Requirement dated, November 28, 2005 (1 Page) is being facsimile transmitted under Rule 37 CFR 1.61(d) to the U.S. Patent and Trademark Office to (571) 273-8300 on December 28, 2005.


Dr. Daniel P. Morris, Esq.
Reg. No. 32,053**RESPONSE TO RESTRICTION REQUIREMENT**

For purposes of examination applicants select from species in Claim 1 a polysulfone resin and from the species in Claim 6 cyclic olefins. Claims 1-6, 18 and 20 are readable therein.

Please charge any fee necessary to enter this paper and any previous paper to deposit account 09-0468.

Respectfully submitted,

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